Measurement of Grain Boundary Properties in Cu(In,Ga)Se₂ Thin Films

S. Rozeveld,¹ C. Reinhardt,¹ E. Bykov,² and A. Wall²

¹Dow Chemical Company, Analytical Science, 1897 Building, Midland, MI 48667
²NuvoSun, 1565 Barber Lane, Milpitas, CA 95035

*SRozeveld@dow.com

Abstract: Semiconductors CulnSe₂ (CIS) and alloys of Cu(In,Ga)Se₂ (CIGS) are often used as the light absorbing layer in thin film photovoltaic devices. These polycrystalline materials reach good conversion efficiencies despite the presence of grain boundaries, which can degrade device performance. Grain properties such as size distribution and orientation can be characterized using electron backscatter diffraction (EBSD). The EBSD method has been used extensively to determine texture and recrystallization in metal forming processes but to a lesser extent for characterization of CIGS thin film properties. This article describes measurements of grain properties for CIGS thin films grown under different reaction conditions.

Keywords: electron backscatter diffraction (EBSD), chalcopyrite semiconductors, thin film photovoltaic devices, grain boundaries, grain size

Introduction

The demand for solar energy continues to climb with over 50 GW/year of photovoltaics installed globally in recent years [1, 2]. The majority of solar cells are produced from crystalline silicon, but thin film materials such as CulnSe₂ (CIS) and alloys of Cu(In,Ga)Se₂ (CIGS) have also been shown to be good light absorbers for thin film photovoltaic devices with conversion efficiencies above 14% in commercial modules [1–3].

Polycrystalline CIGS thin films have grain size on the order of 0.3–2.0 µm depending on deposition and process conditions [4–8]. When the average grain size is smaller than the thickness of the CIGS film, the generated current will pass through multiple grain boundaries, which are potential recombination centers for the charge carriers [3–5]. For many semiconductors materials such as Si or GaAs, the presence of grain boundaries will degrade the solar cell performance; however, polycrystalline Cu(In,Ga)Se₂ solar cells can reach good conversion efficiencies despite the presence of a high grain boundary density [5, 8]. Rau et al. modeled the influence of GBs on CIGS solar cell efficiencies and predicted a decrease in efficiency when the defect density at the grain boundary exceeded ~ 10¹¹ cm⁻² [9]. This trend appeared over a wide range of defect energies, and their results predict a significant decrease in efficiency for CIGS films with a small grain size [9]. This article describes some experiments to better understand the effect of grain boundaries on CIGS thin film photovoltaic performance.

Materials and Methods

Specimen preparation. Conventional scanning electron microscopy (SEM) images of thin film surfaces were recorded using a FEI Helios NanoLab G3 dual-beam focused-ion-beam SEM. Prior to the SEM analysis, the CIGS cells were etched in dilute (10% vol.%) HCl solution for several minutes to remove the top contact layers, which consisted of a transparent conductive oxide and CdS film. The CIGS thin films were fabricated at NuvoSun using a two-stage process in which a Cu-Ga-In alloy precursor was first partially selenized and then fully selenized at ~ 550–600°C in a separate reactor roll-to-roll line. A focused-ion beam of 9.3 nA was used to ion-polish the sample surface at a glancing angle prior to electron backscatter diffraction (EBSD) experiments. The milled region was about 50 µm wide, which provided a relatively large area for EBSD. Atomic force microscopy (AFM) showed that ion milling removed about 100–200 nm of material.

Electron backscatter diffraction. EBSD has been used extensively to determine grain properties such as texture and recrystallization, as well as failure analysis and strain mapping, but only to a limited extent for CIGS thin films [10–12]. In this study, EBSD patterns were collected for different thin film samples in order to determine the grain size distribution and orientation [10–12]. A typical instrument configuration is shown in Figure 1a, which shows a Helios FIB-SEM and EDAX EBSD detector. Figure 1b shows the orientation of the sample with respect to the EBSD detector.

The EBSD data were collected using an EDAX detector with OIM-Team software at 20 keV, 13 nA electron current.
Amira Software for Cell Biology

Universal 3D/4D+ software platform for discovery workflows

From imaging to understanding living cells, Thermo Scientific™ Amira™ Software for Cell Biology supports entire R&D workflows. Process and visualize data from any imaging modalities, at any scale, of any size. Perform routine and advanced analyses of cellular processes from a single platform. Customize your Amira Software workflow for even greater insight into your data.

Find out more at thermofisher.com/amira-avizo
Grain Boundary Properties

8 mm working distance, and a magnification of 10 kx. Experimental EBSD conditions were as follows: map size area = 12 µm × 12 µm; pixel size (medium) = 0.04 µm, the bin size = 5 × 5; gain = 300, exposure time = 3.66 msec, frame averaging = 5, frames per second = 270 fps (~55 patterns per sec with frame averaging of 5x).

The EBSD signal originates from approximately the top ~20 nm of the sample, and therefore the quality of EBSD data is sensitive to crystal perfection near the surface [10–13]. The CIGS structure is tetragonal, with a c/a of ~2.0, but the structure was indexed assuming a pseudo cubic symmetry to improve the indexing [13]. The orientation of each pixel is calculated during pattern collection and assigned a confidence index based on the quality of the pattern. After the entire data set of EBSD patterns is collected, each pixel is assigned to a specific grain. For pixels that had a low confidence index, a standard clean-up procedure was applied to assign pixels to grains. The clean-up procedure consisted of single “grain dilation” for each data set using the following criteria: (1) a grain must contain multiple rows of pixels, (2) single dilation iteration, (3) pixel size of 0.04 µm (40 nm), (4) minimum grain size of five pixels, and (5) an inter-grain tolerance angle of 5 degrees. Grains smaller than 0.1 µm were not included in grain-size analysis. Similar EBSD work by Abou-Ras et al. used an Ar ion milling procedure to prepare cross-sectional CIGS samples to minimize the beam damage. The pixel size used for their investigation was 10–50 nm, and the authors excluded grains with diameters ≤ 0.2 µm [8].

Atomic force microscopy. Samples of etched and ion-polished CIGS were imaged using peak force (PF) tapping AFM techniques. The AFM images were obtained on a Bruker Icon using a Nanoscope V controller (software v.8.15). Cantilevers employed were Bruker Scanasyst (air) with the following settings: PF set point = 1.2 V; noise threshold = 0.5 nm; PF amplitude = 300 nm; Z range = 12 µm; PF engagement set point = 0.15 V. Scan sizes were 50 µm × 50 µm. All images were captured at 1024 lines of resolution. All images were produced using SPIP v.6.3.5 software (Scanning Probe Image Processor, Image Metrology, Denmark). A 2nd order average plane fit with a zero-order LMS and mean set to zero plane fit was used to flatten the images. All postprocessing measurements were done using SPIP software as well.

Results

CIGS cells : process and device properties. The grain properties (size, texture, and relative orientation) were investigated using EBSD of cells that were grown under different reactor conditions but which had a similar level of performance (Table 1). Device efficiencies ranged from 10–11% efficiency, and the open circuit voltage (Voc) ranged from 590 mV to 629 mV.

Surface roughness of as-received NuvoSun CIGS. AFM was used to investigate the morphology and roughness of the as-received CIGS surfaces for the various devices. Figures 2a-2c show AFM images of the surfaces that indicated the grain structure for Device 1 was more faceted compared to Devices 2 and 3. The average surface roughness of the CIGS films, as measured by AFM techniques, varied from 60 nm to 94 nm. Figure 3 shows SEM images of CIGS film surfaces. The SEM images also revealed variations in surface structure and roughness among the samples, and all of the as-received samples contained sub-micron porosity, typically located at grain boundary junctions.

EBSD of NuvoSun cells. Grain orientation maps, derived from the EBSD patterns, are usually displayed in inverse pole

<table>
<thead>
<tr>
<th>Device ID</th>
<th>Efficiency</th>
<th>Voc</th>
</tr>
</thead>
<tbody>
<tr>
<td>Device 1</td>
<td>10.9</td>
<td>0.613</td>
</tr>
<tr>
<td>Device 2</td>
<td>11.4</td>
<td>0.613</td>
</tr>
<tr>
<td>Device 3</td>
<td>11.0</td>
<td>0.590</td>
</tr>
</tbody>
</table>

Table 1: NuvoSun cell performance. Device efficiency (in %) and open circuit voltage (Voc in volts) for each device. The solar cell efficiency refers to the efficiency of converting light into electricity. Open-circuit voltage, the maximum voltage available from a solar cell, is also a measure of performance. Commercial devices with polycrystalline silicon have open-circuit voltages on the order of ~ 600 mV, whereas organic solar devices can have open-circuit voltages in excess of 600 mV.

Figure 2: AFM images for Devices 1 to 3 in images (a) to (c). Fields of view are 10 µm × 10 µm. The average surface roughness (Ra) values for the cells were determined from 50 µm × 50 µm regions. The Ra values by AFM for Devices 1–3 were 60.1 nm, 73.8 nm, and 94.7 nm, respectively.
Grain Boundary Properties

Figure 3: SEM plan view images and EBSD inverse pole figures (IPFs) of the CIGS surface for the three devices. (a–c) SEM surfaces images of Devices 1–3. (d–f) Corresponding inverse pole figures from etched CIGS surfaces (IPF raw data) for Devices 1–3. The red, green, and blue refer to grains with <001>, <102>, and <112> orientations. The average AFM surface roughness (Ra) values for the cells were 60.1 nm, 73.8 nm, and 94.7 nm, respectively. Note that the SEM images and IPF maps were from not the same areas. No cleaning steps were applied to these IPF maps. Image width = 7.5 μm.

Figure 4: (a) Quadrant of stereogram and (b) standard triangle showing the coloring scheme used in IPFs for tetragonal symmetry with c/a ratio = 2.0.
used to reduce the sample roughness. In this technique, the samples were ion-milled at a glancing angle to the surface. Figure 5 shows SEM images of a CIGS surface before and after ion milling.

The goal of the ion-milling step was to remove a minimum amount of material (~100 nm) that would improve the EBSD pattern quality and still allow information on the grain size and orientation to be obtained near the original surface. This depth represents ~10% of the total CIGS films thickness (~1.2 µm). Ion-milling was done at a glancing angle for several minutes over a width of 50 µm to provide a sufficient area for EBSD analysis. AFM measurements indicated that the surface roughness decreased substantially after ion-milling; however, typically ~200–250 nm was removed from the surface by ion-milling in order to provide a smooth surface. The depth of the CIGS removed during the ion-milling step was estimated by using AFM measurements of the median height difference between the ion-polished and as-received regions as shown in Figure 6.

Figure 7 shows inverse pole figures after ion-polishing for Devices 1–3. In general, we observed that the quality (confidence index) of the EBSD patterns collected from ion-polished surfaces was lower compared to as-received surfaces. This was attributed to surface damage from Ga ion-implantation during ion-milling; however, the quality of EBSD patterns collected from ion-milled surfaces was sufficient for indexing of the grains without additional surface treatment (for example etching or Ar ion milling to remove surface damage). It is interesting to note that while porosity was observed in all devices (based on both SEM imaging and EBSD data), it does not appear to degrade device performance dramatically at this efficiency level since all devices had 10–11% efficiency. Regions with a low confidence index (pores) are denoted in black. The EBSD patterns were collected over regions 12 µm × 12 µm in size for each sample in order to collect a sufficient number of grains for statistical analysis, but a smaller region (7 µm × 7 µm) is shown in Figure 7 for clarity.

**Grain size measurements.** The EBSD data were used to determine the grain size distribution for Devices 1–3 (Figure 8). The average grain size for Device 1 was ~0.6 µm, which was significantly larger than the average size ~0.4 µm for Devices 2 and 3. The CIGS grain size diameter can be reasonably represented by a log-normal distribution as shown in Figure 8.

The performance levels of Devices 1–3 were all similar, and therefore the average grain size did not correlate with device performance at this efficiency level of 10–11%. This result is consistent with previous work, which showed that the grain size has a limited impact on device performance, and other factors such as recombination at the heterojunction interface, internal potential fields, or recombination at the back contact may play more significant roles [3, 8]. In addition, the role of the relative grain orientation or porosity may also be a limiting factor to attainment of higher efficiencies. It is interesting to note that Device 2 was annealed for additional time (40 minutes) at 600°C in an Se reactor to promote grain growth compared to Device 1, but this anneal did not have a significant effect on grain growth.

**Grain boundary type.** The distribution of low- and high-angle grain boundaries was also investigated.
Low-angle grain boundaries are defined as adjacent grains with only 2°–15° misorientation. The misorientation angle between grains is shown in Figures 9a and 9b for Devices 1 and 3. Most grain boundaries were high-angle (shown in blue), and special high-symmetry grain boundaries of 60° are denoted by green color. An alternate way of presenting the data is to show the distribution of misorientation angles between adjacent grains as shown in Figures 9c and 9d, which indicated that few low-angle grain boundaries were present (red lines).

The misorientation angles shown in Figures 9c and 9d exhibit a broad distribution centered on 40°–45°, which is consistent with a random orientation [11]. This result agrees with X-ray diffraction measurements conducted on similar devices grown using a two-step selenization process. Conversely, thin films of CIGS grown by co-evaporation often display <220/204> and <112> grain textures [7].

Discussion

There are several proposed models used to explain the properties of grain boundaries in CIGSe [3, 7, 15]. In the electronic barrier model, trapped charge at the grain boundary causes local bending of the conduction and valence bands adjacent to the grain boundary. In this model, a downward band bending toward GBs would favor recombination of carriers, while an upward band bending would repel minority carriers and reduce recombination [15, 16].

Baier et al. investigated the symmetry of GBs that influences GBs electronic properties [15]. Their results showed that special (Σ = 3) grain boundaries typically were neutral (zero potential), while the non-Σ = 3 grain boundaries had a wider range in potential from positive to negative. Hannah et al. also investigated CIGS samples, and their results indicated that samples with a random texture had a more negative contact potential near the grain boundaries compared to the samples with a strong (220/204) texture [16]. These studies suggest the grain boundary orientation and grain boundary defects may limit device performance as predicted by Rau et al. [9].

Kelvin probe force microscopy (KPFM) is one method that has been used to obtain spatially resolved information of the work function at the grain boundary and at adjacent grains [15, 16]. Similar experiments are currently in progress to characterize the surface potential of CIGS devices near the heterojunction interfaces and grain boundaries using KPFM and EBSD in order to better understand the correlation between grain boundary misorientation and device efficiency.
**Conclusion**

Collection of high-quality EBSD grain size and grain orientation data from as-received CIGS devices was limited due to the surface roughness, and many grains could not be properly indexed. This issue was circumvented by ion-polishing the CIGS samples at a glancing angle to reduce surface roughness. The quality of EBSD patterns after ion-polishing was adequate for indexing, although the patterns were then collected at a depth of ~200–250 nm from the original surface.

The CIGS grain size did not have a significant impact on device performance (at this level of efficiency), and other factors are expected to play a dominant role. The EBSD results indicated that the majority of grain boundaries in these devices were high-angle boundaries. The EBSD results also showed that the CIGS films did not have a strong texture, which agrees with previous X-ray diffraction measurements for devices grown using a two-step selenization process. Typically, CIGS thin films grown by co-evaporation will often display a <220/204> and <112> grain texture.

The SEM and EBSD data indicated that there was a significant variation in the porosity among the different devices, but this did not lead to differences in device performance. The extent to which the high-angle grain boundaries and porosity will limit device performance at higher efficiency levels is under investigation.

**Acknowledgements**

The authors wish to thank S. I. Wright and M.M. Nowell of EDAX for their guidance in the EDSB analysis.

**References**


Hoyer’s Microscopic Slide Mounting Medium

If you have been around microscopy, you know Hoyer’s Medium. Now available in the U.S.

Hoyer’s Medium is a high-purity, high IR, solvent-free medium that makes mounted specimens look clear and fresh even after years of storage. Hoyer’s Medium is free of known carcinogens and will not cloud or darken. It is available in a range of sizes, from 10ml to laboratory-scale quantities of 10L. Sizes 10ml, 30ml, 50ml are supplied in LDPE squeeze bottle containers with precision blunt steel needle tips and covers. Larger sizes are supplied in LDPE bottles with screw tops.

Hoyer’s has a high index of refraction, making it the preferred medium for creating permanent microscope slide mounts of insects, plants, animal tissue samples, chromosome squashes, etc.

Pure Hoyer’s solution
- Allows accurate comparison of historical slides mounted with Hoyer’s medium
- Resists yellowing and recrystallization
- Available in multiple sizes.

Hoyer’s is a product of Great Britain and ships from Hempstead Halide Inc. in the US.